

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Patent No.: 6,998,625  
Issue Date: February 14, 2006  
Title: Ion Implanter Having Two-Stage Deceleration Beamline  
Assignee: Varian Semiconductor Equipment Associates, Inc.  
Inventors: Charles M. McKenna et al.  
Art Unit: 2881

**STATEMENT UNDER 37 CFR §1.324(b)(1) FROM THE PERSON BEING ADDED AS AN INVENTOR**

Sir:

I, **MANNY SIERADZKI**, state that the inventorship error of failing to include me as an inventor of the above-referenced patent occurred without any deceptive intention on my part.

Respectfully Submitted,

Date:

27 August 2007

By:

Manny Sieradzki

